

- L8: (5) 3 and reaction near3 product with (high-K high?K high adj K thermal
- L9: (913) (257/310).CCLS.
- L11: (0) 9 and reaction near3 product with (high-K high?K high adj K therm
- L10: (11) 9 and reaction near3 product
- L7: (15) composite near3 dielectric with reaction with (high-K high?K high
- L12: (813) (257/900,e21.64,e21.626).CCLS.
- L13: (0) 12 and 5
- L14: (4174) (257/310,635,758).CCLS.
- L15: (44) 14 and reaction near3 product
- L16: (0) 14 and reaction near3 product with (high-K high?K high adj K them
- L17: (3) 15 and (high-K high?K high near3 thermal near3 coefficient\$3)
- L18: (2) 15 and (high-K high?K high near3 thermal near3 expansion near3 co
- L19: (3) 15 and (high-K high?K high near3 thermal near3 expansion near3 co
- L20: (6023) (438/197,200,240,261,287,585,591,761,785,791).CCLS.
- L21: (5) 20 and reaction near3 product with (high-K high?K high adj K them

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Default operator: OR ☒ Highlight all hit terms initially

20 and reaction near3 product with (high-K high^K high adj K thermal near3 coefficient\$3)

Results: 0

	U	I	Document ID	Issue Date	Page	Title	Current O	Current X	Retrieval	Inventor	S	C
1	□	□	US 6790755 B2	2004091	13	Preparation of stack high	438/591	257/E21.6		Jeon, Joong	□	□
2	□	□	US 6740605 B1	2004052	15	Process for reducing hyd	438/795	438/471,		Shiraiwa, Hidehiko	□	□
3	□	□	US 6645882 B1	2003111	13	Preparation of composite	438/785	438/791		Halliyal, Arvind et	□	□
4	□	□	US 6642573 B1	2003110	15	Use of high-K dielectric	257/316	257/E21.2		Halliyal, Arvind et	□	□
5	□	□	US 6559014 B1	2003050	13	Preparation of composite	438/287	257/E21.1		Jeon, Joong	□	□